

## ISW

## PATENT APPLICATION

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Yasuhiro OMURA Group Art Unit: 2882

Application No.: 10/587,254 Examiner: C. KREUTZER

Filed: June 1, 2007 Docket No.: 128834

For: OPTICAL SYSTEM, EXPOSURE SYSTEM, AND EXPOSURE METHOD

## RESPONSE TO RESTRICTION REQUIREMENT

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In reply to the January 5, 2010 Restriction Requirement, Applicant provisionally elects Group I, claims 30-49, 94-102 and 120-128, with traverse.

It is respectfully submitted that the subject matter of all claims is sufficiently related that a thorough search for the subject matter of any one Group of claims would encompass a search for the subject matter of the remaining claims. Thus, it is respectfully submitted that the search and examination of the entire application could be made without serious burden. See MPEP §803 in which it is stated that "if the search and examination of an entire application can be made without serious burden, the examiner <u>must</u> examine it on the merits, even though it includes claims to independent or distinct inventions" (emphasis added). It is respectfully submitted that this policy should apply in the present application in order to avoid

unnecessary delay and expense to Applicant and duplicative examination by the Patent Office.

Thus, withdrawal of the Restriction Requirement is respectfully requested.

Respectfully submitted,

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MAC:MQW/tbm

Date: February 5, 2010

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